

TKHR**THOMAS, KAYDEN, HORSTEMEYER & RISLEY, L.L.P.**

ATTORNEYS AT LAW

100 Galleria Pkwy, NW
Suite 1750
Atlanta, GA 30339-5948
www.tkhr.com

Eric Ringer

eric.ringer@tkhr.com

FACSIMILE TRANSMISSION

August 13, 2004

[062002-1751]**TO**

Parvis Hassanzadeh

FAX: 571 273 1435**TEL: 571 272 1435****FROM**

Eric Ringer

FAX: 770-951-0933**TEL: 770 933 9500****RE: 09/855,972**

(Message) Examiner Hassanzadeh, this is transmission 2 of 5.

Number of Pages (Including This Cover Sheet): - 24 - Page(s)
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I hereby certify that this correspondence is being transmitted by facsimile to:

ATTN: Parvis Hassanzadeh
Facsimile number: 571 273 1435
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

on August 13, 2004.


Eric Ringer

In re application of:	Kevin P. Martin et al.	Confirmation No.:	1603
U.S. Serial Number:	09/855,972	Art Unit:	1763
Filing Date:	May 15, 2001	Examiner:	Hassanzadeh, Parvis
Our Reference Number:	62002-1751		

Title: Method and Apparatus for Low Energy Electron Enhanced Etching or Substrates in an AC or DC Plasma Environment

3 Cited References (Articles Only)